

	Type	L #	Hits	Search Text	DBs	Time Stamp	Com m e n t s	Er r o r s
1	BRS	L1	174	(organic adj (ARC or ARL or (antireflect\$3 adj (layer or coating or material)))) and etch\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/25 13:24		0
2	BRS	L22	13	(organic adj (ARC or ARL or (antireflect\$3 adj (layer or coating or material)))) same (etch\$3 and (Cl2 or chlorine))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/25 14:39		0
3	BRS	L30	12037	((CF4 or "tetrafluoro methane" or "carbon tetrafluoride" or CHF3 or "trifluoromethane" or C2F6 or "hexafluoro ethane" or CH2F2 or "difluoro methane" or (difluoride adj methane)) nd (Cl2 or chlorine)) same etch\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/25 15:09		0
4	BRS	L37	738	((CF4 or "tetrafluoro methane" or "carbon tetrafluoride" or CHF3 or "trifluoromethane" or C2F6 or "hexafluoro ethane" or CH2F2 or "difluoro methane" or (difluoride adj methane)) and (Cl2 or chlorine)) same etch\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/25 15:53		0
5	BRS	L44	281	37 and @pd<=19961231	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/25 15:59		0
6	BRS	L51	340	((CF4 or "tetrafluoro methane" or "carbon tetrafluoride" or CHF3 or "trifluoromethane" or C2F6 or "hexafluoro ethane" or CH2F2 or "difluoro methane" or (difluoride adj methane)) and (Cl2 or chlorine) and (Ar or argon or helium or He or Ne or neon or Kr or krypton or Xe or xenon)) same etch\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/25 15:55		0
7	BRS	L58	115	51 and @pd<=19961231	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/25 16:00		0